

# Comparison of milligram scale deadweights to electrostatic forces

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## ABSTRACT

This paper presents a comparison of milligram scale deadweights to electrostatic forces via an electrostatic sensing & actuating force measurement system. The electrostatic sensing & actuating force measurement system is designed for measuring force below 200  $\mu\text{N}$  with an uncertainty of few nanonewton. The force measurement system consists of three main components: a monolithic flexure stage, a three-electrode capacitor for position sensing and actuating and a digital controller. The principle of force measurement used in this system is a static force balance, i.e. a force to be measured is balanced by a precisely controlled, electrostatic force. Four weights of 1 mg to 10 mg were tested in this comparison. The results of the comparison showed that there exist extra stray electrostatic forces between the test weights and the force measurement system. This extra electrostatic force adds a bias force to the measurement result, and was different for each weight. In principle, this stray electrostatic force can be eliminated by installing a metal housing to isolate the test weight from the system. In the first section, we briefly introduce the electrostatic sensing and actuating force measurement system, and then we describe the experimental setup for the comparison and the results. Finally, we give a discussion and outlook.

## Section: RESEARCH PAPER

**Keywords:** Deadweight force standard; electrostatic force actuation; capacitive position sensing; force balance

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## 1. INTRODUCTION

Micro- and nano-force measurement is of great interest in recent years among several national measurement institutes (NMIs) [1-6]. The Center for Measurement Standards (CMS) of the Industrial Technology Research Institute (ITRI) has established a force measurement system based on electrostatic sensing and actuation techniques. The system is capable of measuring vertical forces up to 200  $\mu\text{N}$  based on a force balance method. The system mainly consists of a flexure stage, a three-electrode capacitor and a digital controller [7]. The

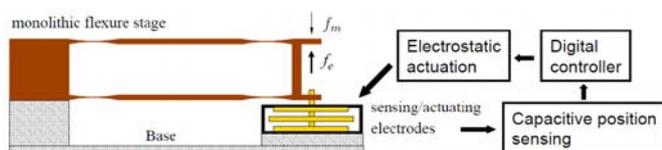


Figure 1. Schematic drawing of the force measurement system.

schematic drawing of the system is shown in figure 1.

The three-electrode capacitor is used simultaneously as a capacitive position sensor and an electrostatic force actuator. The position of the center electrode is measured by comparing the capacitances between upper capacitor  $C_1$  and lower capacitor  $C_2$  formed within the three electrodes (see figure 2). The differential capacitance was detected using an inductive-capacitive resonant bridge circuit. The position detection is performed at a radio frequency (RF), say, 100 kHz, a frequency depending on the capacitance values and the design of the sensing bridge circuit. For electrostatic force actuation, the top and bottom electrodes are applied with two high voltage, audio frequency sinusoidal signals to generate a compensation electrostatic force  $f_e$  to balance the force under measurement  $f_m$ . The balance condition  $f_m = f_e$  is maintained by the digital controller by keeping the flexure stage at its zero deflection position. Some parts of the force measurement system were upgraded for performance improvements. A new design of

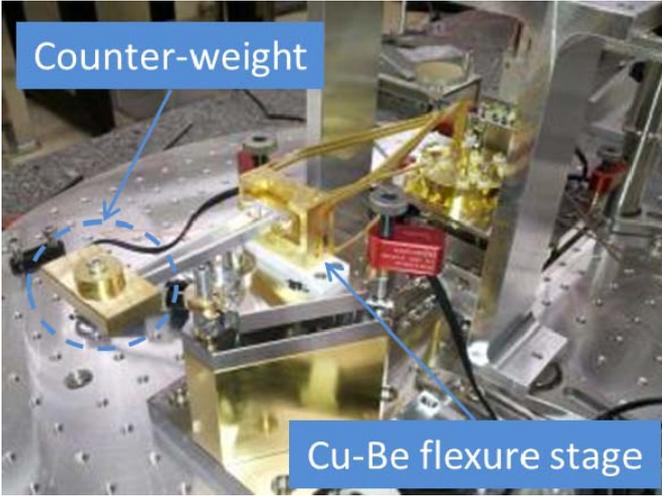


Figure 2. Picture of the new flexure stage.

copper-beryllium flexure stage was installed in the system, which has a counter weight balance mechanism and a lower stiffness of 13.08 N/m. Figure 2 shows a picture of the new flexure stage, where the counter weight and the gold-plated Cu-Be flexure stage are visible. A new set of gold-plated, polished electrodes was assembled as a three-electrode capacitor and put into operation. The capacitance gradient for the new three-electrode capacitor was measured.

## 2. EXPERIMENTAL SETUP

In this experiment, the compensation electrostatic force is compared to the deadweight by weighing a weight with the electrostatic sensing and actuating force measurement system.

### 2.1. Deadweight

We used five wire weights with nominal mass values and shapes of 1 mg-triangle, 2 mg-square, 5 mg-pentagon and 10 mg-triangle to generate vertical downward forces. These weights meet the metrological requirement of the OIML class E1 and were calibrated against standard weights using a mass comparator balance. The calibration results are compiled in Table 1. The forces can be derived from the calibrated mass values and the local acceleration of gravitation  $g = 9.78914 \text{ m/s}^2$  as  $f_w = m(1 - \rho_a/\rho_w)g$ , where  $\rho_a$  and  $\rho_w$  are densities of the air and the weight, respectively. These weights were loaded and unloaded by a DC motor actuated linear translation stage.

### 2.2. Electrostatic sensing & actuating force measurement system

As shown in Figure 3, the compensation electrostatic force  $f_e$  generated by the force measurement system is determined by the following equation:

$$f_e = \frac{1}{2}S_1V_1^2 + \frac{1}{2}S_2V_2^2 \quad (1)$$

where  $S_1, S_2$  are the capacitance gradients of the top and the bottom capacitors  $C_1, C_2$  and  $V_1, V_2$  are voltage potentials between the top and the bottom capacitors, respectively. Using the parallel-plate capacitor as the model for capacitor  $C_1$  and  $C_2$ ,

Table 1. Mass calibration result.

Nominal mass (mg)	Conventional mass (mg)	Uncertainty, 95% confidence (mg)
1	1.00096	0.0003
2	2.00116	0.0003
5	5.00124	0.00065
10	10.0021	0.00048

$$C_1(x) = \frac{\varepsilon_0 A}{d-x} = \frac{\varepsilon_0 A}{d} \left[ 1 + \frac{x}{d} + \left(\frac{x}{d}\right)^2 + \left(\frac{x}{d}\right)^3 + \left(\frac{x}{d}\right)^4 + \dots \right] \quad (2)$$

$$C_2(x) = \frac{\varepsilon_0 A}{d+x} = \frac{\varepsilon_0 A}{d} \left[ 1 - \frac{x}{d} + \left(\frac{x}{d}\right)^2 - \left(\frac{x}{d}\right)^3 + \left(\frac{x}{d}\right)^4 + \dots \right] \quad (3)$$

where  $\varepsilon_0$  is the vacuum permittivity,  $A$  is the effective area of the electrode and  $d$  is the gap distance between electrodes when the center electrode is vertically centered. The capacitance gradients  $S_1$  and  $S_2$  can be expressed as

$$S_1(x) = \frac{dC_1}{dx} = S_0 \left[ 1 + 2\frac{x}{d} + 3\left(\frac{x}{d}\right)^2 + 4\left(\frac{x}{d}\right)^3 + 5\left(\frac{x}{d}\right)^4 + \dots \right] \quad (4)$$

$$S_2(x) = \frac{dC_2}{dx} = S_0 \left[ -1 + 2\frac{x}{d} - 3\left(\frac{x}{d}\right)^2 + 4\left(\frac{x}{d}\right)^3 - 5\left(\frac{x}{d}\right)^4 + \dots \right] \quad (5)$$

where  $S_0 = \varepsilon_0 A/d^2$  is the capacitance gradient at  $x=0$ . The electrostatic force can be written as

$$f_e(x) = \frac{1}{2}S_0(V_1^2 - V_2^2) + \frac{x}{d}S_0(V_1^2 + V_2^2) \quad (6)$$

The voltages  $V_1$  and  $V_2$  contain the RF detection signal  $V_d \sin \omega_d t$ , audio frequency high voltage actuation voltages  $V_{a1} \sin \omega_a t$ ,  $V_{a2} \sin \omega_a t$  and the electrodes' surface potentials  $v_{s1}, v_{s2}$ , namely

$$V_1 = V_d \sin \omega_d t + V_{a1} \sin \omega_a t + v_{s1} \quad (7)$$

$$V_2 = V_d \sin \omega_d t + V_{a2} \sin \omega_a t + v_{s2} \quad (8)$$

The high voltage actuation signals are provided by a full range  $\pm 10 \text{ V}$  16-bit resolution digital-to-analog converter within the digital controller and an ultra low-noise high-voltage amplifier. To make the electrostatic force linearly proportional to a control voltage  $v_c$  we set

$$V_{a1} = A_1(V_b + v_c) \quad (9)$$

$$V_{a2} = A_2(V_b - v_c) \quad (10)$$

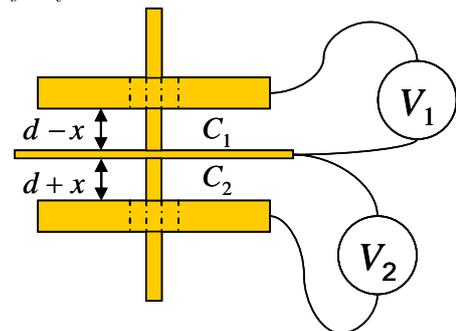


Figure 3. Three-electrode capacitor for electrostatic force actuation.

where  $A_1, A_2$  are amplification factors of the high-voltage amplifier. The term  $V_b$  is a constant and determined by the value of  $S_0$  and the upper limit of the force measurement range. Taking the gain difference between channels of the high-voltage amplifier, substituting equations (7)-(10) for  $V_1$  and  $V_2$  in equation (6), we obtain an equation for the electrostatic force  $f_e$

$$f_e = S_0 A_0^2 V_b v_c + S_0 A_0^2 (a+b)(v_c^2 + V_b^2) + S_0 (v_s^2 + bV_d^2), \quad (11)$$

+ (ac terms)

where  $a$  is the gain difference fraction, i.e.  $a=(A_1-A_2)/(A_1+A_2)$ ,  $A_0$  is the mean gain factor,  $b$  is the offset fraction  $x/d$ ,  $v_s^2 = (v_{s1}^2 - v_{s2}^2)/2$  and  $v_c$  is the control voltage. The high frequency AC terms at audio and RF frequencies can be omitted because they cause only negligible ac displacement modulations on the flexure stage.

Parameter  $a$  can be tuned to very close to zero by adjusting the gain of the DAC within a software program. After the tuning, parameter  $a$  was measured to be smaller than  $5 \times 10^{-5}$  contributing to a negligible force uncertainty. Instead of using an optical interferometer, the position of the center electrode is measured by the difference between  $C_1$  and  $C_2$  with a differential capacitance bridge circuit [7]. Hence, any deviation of the center electrode from the vertical center position can be detected by the bridge circuit. With a commercially available optical interferometer, the offset adjustment could be quite difficult and ambiguous. The effect of parameter  $(a+b)$  can be tested by setting  $v_c = 0$ , modulating  $V_b$  with a square wave profile and observing the displacement signal of the flexure stage. For  $V_b=2.0$ , we did not observe the displacement due to the modulated  $V_b$ .

The remaining factors  $S_0, v_c$  and  $v_s$  dominate the uncertainty of the electrostatic force  $f_e$ . The capacitance gradient  $S_0$  was measured using a weight of 1 mg and a set of optical interferometer. The weight of 1 mg was cyclically loaded and unloaded to the system by a motorized linear stage to produce a deflection modulation. The deflection was measured by the optical interferometer and the corresponding capacitance variation was measured by a calibrated precision capacitance bridge. To reduce the effect from seismic noise and drift noise from the optical interferometer or the flexure stage itself, both deflection  $\Delta x$  and capacitance variation  $\Delta C$  are measured from the difference between average values of mass loaded data and two adjacent mass unloaded data. The capacitance gradient  $S_0$  was obtained by calculating the ratio of  $\Delta C/\Delta x$  which is shown in Figure 3. Using (2) and (3), the capacitance gradient estimated by  $\Delta C/\Delta x$  can be expressed as

$$\begin{aligned} S' &= \frac{C(\Delta x) - C_0}{\Delta x} \\ &= \frac{\epsilon_0 A}{d^2} \left[ 1 + \frac{\Delta x}{d} + \left( \frac{\Delta x}{d} \right)^2 + \left( \frac{\Delta x}{d} \right)^3 + \dots \right] \\ &\cong S_0 \left( 1 + \frac{\Delta x}{d} \right) \end{aligned} \quad (12)$$

From (12),  $S_1'$  deviates from  $S_0$  by a small portion of  $S_0 \Delta x/d$ . Using the nominal design value of  $d = 0.5$  mm, the ratio  $\Delta x/d$  is 0.15 %. This ratio can be reduced by using a smaller  $\Delta x$  for measuring the capacitance gradient. The measured capacitance

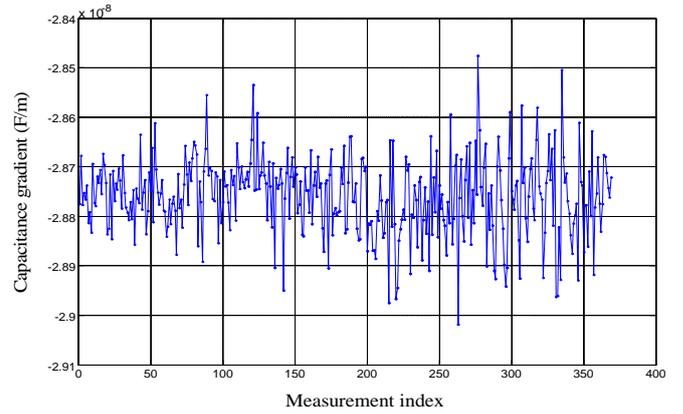


Figure 4. Capacitance gradient calculated from  $\Delta C/\Delta x$ . The mean capacitance gradient  $S_0 = 2.876 \times 10^{-8}$  F/m, standard deviation  $\sigma_s = 0.008 \times 10^{-8}$  F/m and standard deviation of the mean  $\frac{\sigma_s}{\sqrt{N}} = 4 \times 10^{-12}$  F/m ( $N = 369$  in

this measurement).

gradient  $S'$  has a mean value of  $S' = 2.876 \times 10^{-8}$  F/m and a standard deviation of  $\sigma_{S'} = 0.008 \times 10^{-8}$  F/m. Therefore, the standard uncertainty of the capacitance gradient is

$$u(S') = \frac{\sigma_{S'}}{\sqrt{N}} = 4 \times 10^{-12} \text{ F/m with } N = 369 \text{ in this measurement.}$$

The uncertainty  $u(v_c)$  of the control voltage  $v_c$  is calculated using the DAC resolution of 0.3 mV as  $u(v_c) = 0.3/(2\sqrt{3}) = 0.088$  mV which contributes 1 nN.

For the surface potential noise  $v_s$ , the current actuation scheme prevents the surface potential effect from being coupled to and amplified by the control voltage  $v_c$  as the case in the previous electrostatic actuation scheme [7] where  $v_s$  was amplified as  $Sv_s$ . The surface potential is reported to range from 20 mV to 180 mV [8, 9]. Taking  $v_s = 0.18$  V for example and  $S = 2.876 \times 10^{-8}$  F/m, the surface potential induced electrostatic force is about 0.9 nN.

### 2.3. Null deflection control

The force under measurement  $f_m$  is balanced by  $f_e$  by the null deflection control. Figure 5 shows the block diagram of the null deflection control. The transfer functions of the main components, namely the flexure stage, capacitive position sensor, loop filter and the electrostatic force actuator, are represented by  $G, H, D$  and  $A$  respectively. The term  $x_n$  represents a deflection noise which may be contributed by the seismic vibration noise and the thermal noise of the flexure stage itself. The relation between  $f_e$  and  $f_m$  appears to be

$$F_e(s) = -\frac{HDA}{1+T(s)} X_s(s) - \frac{T(s)}{1+T(s)} F_m(s) \quad (13)$$

where  $T(s) = GDHA$  is the open-loop transfer function of the control system, and  $F_e(s), X_s(s)$  and  $F_m(s)$  are the Laplace transforms of  $f_e, x_n$  and  $f_m$ , respectively. Within the control bandwidth, i.e. for  $T(s) \gg 1$ , the relation between  $f_e$  and  $f_m$  can be approximated as

$$f_e = -(kx_n + f_m) \quad (14)$$

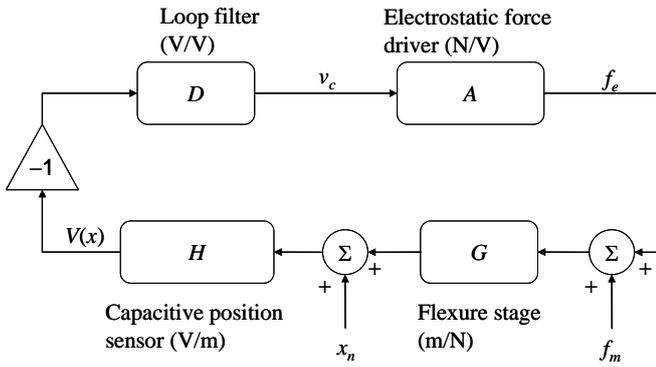


Figure 5. Block diagram of the null deflection control. Some noise sources are omitted for simplicity.

where  $k$  is the stiffness of the flexure stage. Equation (11) shows that the null deflection control automatically generates a compensation force  $f_e$  to balance the force under measurement  $f_m$ . To reduce the influence from the noise  $x_n$ ,  $f_m$  is measured in a short period of time by comparing  $f_e(t_0)$  before  $f_m$  is applied and  $f_e(t_1)$  after  $f_m$  is applied:

$$\Delta f_e = f_e(t_1) - f_e(t_0) = -k[x_n(t_1) - x_n(t_0)] - f_m$$

thus

$$f_m = -\Delta f_e - kx_n \quad (15)$$

The term  $x_{nt}$  represents the temporal variation of  $x_n$  during the measurement time frame. From one deflection measurement data set taken for 8-hr, using a window of 300 s to evaluate  $x_{nt}$ , we obtained a standard deviation of 0.33 nm for  $x_{nr}$ . With a measured value  $k$  of 13.0 N/m, the standard deviation of the  $x_{nt}$  equivalent force noise is 4.3 nN. Table 2 lists the main sources of uncertainty of the measured  $f_m$ .

#### 2.4. Weighing process

Each weight was loaded for 100 seconds and unloaded for 100 seconds. The compensation electrostatic force was calculated from the control voltage  $v_c$ . Figure 6 shows the control voltage  $v_c$  acquired during one weighing cycle. The voltage difference  $\Delta v_c$  was determined from one weight loaded segment and its two adjacent weight unloaded segments as

$$\Delta v_c = v_{cB} - \frac{v_{cA1}}{2} - \frac{v_{cA2}}{2} \quad (16)$$

The weighing cycle was repeated for a long period of time in

Table 2. Uncertainty budget for measured  $f_m$

Source of uncertainty	Standard uncertainty (N)
Capacitance gradient $S_0$	$1.4 \cdot 10^{-4} \Delta f_e$
16-bit DAC resolution	$1 \cdot 10^{-9}$
Surface potential $v_s$	$1.8 \cdot 10^{-9}$
Displacement noise $x_{nt}$	$4.3 \cdot 10^{-9}$
Combined standard uncertainty:	
$u(f_m) = \sqrt{(4.8 \cdot 10^{-9})^2 + (1.4 \cdot 10^{-4} \Delta f_e)^2}$ N	

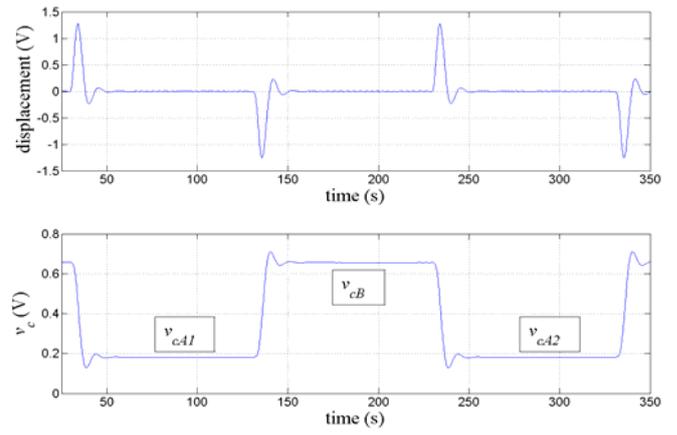


Figure 6. Capacitive displacement and control voltage  $v_c$  during one weighing cycle.

order to evaluate the stability and uncertainty of the system.

### 3. RESULTS

Figure 7 shows the result of one weighing run for the weight of 1 mg. The measurement was done during three days. For this run, the measured electrostatic force was  $f_e = (9,782.6 \pm 6.7)$  nN, where the given uncertainty is one standard deviation. The forces produced from the weights are estimated as  $f_w = mg(1 - \rho_{air}/\rho_{mass})$ , where the air buoyancy was taken into consideration. The comparison results are compiled in Table 3. In general, the electrostatic force has a smaller value than the deadweight. For comparisons of weights 1 mg and 10 mg, the force differences defined as  $f_e - f_w$  are similar and close to 10 nN, and they both are in triangle shapes with similar dimensions. For comparisons of the weight 2 mg and 5 mg, the force differences are rather larger, and they are in shapes of square and pentagon, respectively. The weight of 5 mg has the largest force difference of about 200 nN (20  $\mu$ g), and it is the biggest weight in terms of wire length and shape area dimensions. A possible explanation for this force difference is that there might be some extra electrostatic or magnetic force between the weight and its surroundings. Due to the size of the weight of 5 mg, it has the shortest distances to and possibly experiences the strongest electrostatic/magnetic interactions with its surroundings.

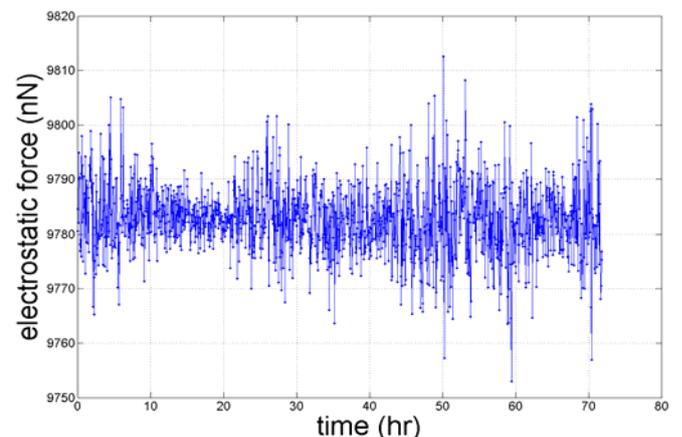


Figure 7. A data run for 1 mg weighing.

Table 3. Comparison results, unit in nN.

	1 mg	2 mg	5 mg	10 mg
$f_w$	9797.1±2.9	19586.7±2.9	48950.5±6.4	97897.3±4.7
$f_e$	9782.6±6.7	19527.0±4.1	48751.4±8.2	97886.4±16.5
$\epsilon f_w$	-14.5	-59.7	-199.1	-10.9

#### 4. DISCUSSION AND OUTLOOK

A force measurement system based on the electrostatic sensing and actuation techniques has been built and upgraded. The system is enclosed by a vacuum chamber which resides on a passive low frequency vibration isolation platform. The voltage actuation scheme has been modified to allow the decoupling between the surface potential  $v_s$  and the actuation voltage leading to a reduction in the drift and bias of the compensation electrostatic force. The system is stable over a long period of time. However, the cause of the extra electrostatic/magnetic force observed in the weighing test is still unclear and investigation to that is underway. A new design of the apparatus's housing is being fabricated, it was designed to isolate most of the apparatus from its surroundings and expose only the force loading area. In addition, other parameters such as alignment factors, the capacitance gradient and its frequency dependence will also be re-verified and studied further to find out the cause for the force difference.

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